

<b>APPLICANT'S ART CITATION</b> <small>(Use several sheets if necessary)</small>		Application <b>10/585,289</b>		OFGS File No. <b>P/2850-144</b>		
		Applicant <b>Takeshi Nakamura</b>				
		Filing Date <b>July 7, 2006</b>		Group Art Unit <b>1755</b>		
<b>U.S. PATENT DOCUMENTS</b> (not submitted for applications filed after 6/30/03)						
	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-6,838,162 B1	01-2005	GRUBER ET AL.			
	US-2003/0008067 A1	01-2003	YAMAGUCHI ET AL.			
	US-					
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<b>FOREIGN PATENT DOCUMENTS</b>						
	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation Yes      No
	CN 1288874	09-2000	CHINA			U.S.P 6,838,162
	JP 2003-20287	01-2003	JAPAN			U.S. PUB. 2003/0008067
<b>OTHER DOCUMENTS</b> (Including Author, Title, Date, Pertinent Pages, Etc.)						
	Office Action issued November 30, 2007 in corresponding Chinese Application No. 200480039952.9 and an English translation					
Examiner		Date Considered				
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.						